

Amendment

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1765

FAX TRANSMISSION SHEET

January 15, 2004

Our Ref : MART4591-R
Appl. No. : 09/759,899
Filing Date : January 12, 2001
Pages : Cover + 6

BY FACSIMILE ONLY

FAX : 703-308-6778
ATTN : Mr. George Allen
United States Patent and Trademark Office
FROM : Jiawei Huang, Reg. No.: 43,330
MESSAGE : Enclosed herewith is copy of the amendment filed on 03/11/2003.

Sir:

I hereby certify that this correspondence is being facsimile transmitted to the Patent and Trademark Office on January 15, 2004 at the above indicated fax number.

Sign by:

Michelle Chang
Michelle Chang

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :

Application No. : 09/759,899
Filed : January 12, 2001
For : TREATMENT ON SILICON OXYGNITRIDE
Applicant : I. T. Chen
Examiner : Ahmed, Shamim
Art Unit : 1765

No fee is believed to be due. However, the Commissioner is authorized to charge any fees required in connection with the filing of this paper to account No. 50-0710 (Order No. MART4591).

AMENDMENT AND RESPONSE TO OFFICE ACTION**BOX Non-Fee Amendment**

Assistant Commissioner of Patents and Trademarks
Washington, DC 20231

Dear Sir:

The Office Action mailed on December 12, 2002 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.

In The Title:

Please substitute the following clean copy title for the pending title:

--METHOD TO REMOVE SILICON OXIDE MATERIAL GENERATED DURING

REMOVAL OF PHOTORESIST--